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**INFORMATION DISCLOSURE CITATION  
IN AN APPLICATION**

APPLICATION NO.: (new) Based on Intl. App.  
No. PCT/IT2002/000774  
FILING DATE: (new)  
FIRST NAMED INVENTOR: .Maccalli et al.  
GROUP ART UNIT:  
ATTORNEY DOCKET NO.: 47966.14.1

**U.S. PATENT DOCUMENTS**

Examiner Initials	Cite No. <sup>1</sup>	Document No. Number-Kind Code <sup>2</sup>	Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
/SM/		2002/0090454A1	07/11/2002	Paisley et al.	
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/SM/		WO02/38838	05/16/2002			<input type="checkbox"/>
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**NON-PATENT LITERATURE DOCUMENTS**

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/SM/		Zhang, J., et al., "Growth Characteristics of SiC in a Hot-Wall CVD Reactor with Rotation", Journal of Crystal Growth 241 (2002) pp. 431-438	<input type="checkbox"/>
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/Sylvia Macarthur/

**DATE CONSIDERED**

09/03/2007

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